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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Demos et al.	Group Art Unit: 3749
Application No: 10/783,748 Confirmation No: 7358	Examiner: Khiem Nguyen
Filed: 2/20/2004	Attorney Docket No: 007034 USAP02/DSM/BCVD/JW
Title: CLEAN PROCESS FOR AN ELECTRON BEAM SOURCE	August 30, 2004 San Francisco, California

SUBMISSION OF FORMAL DRAWINGS AND CORRECTION TO FILING RECEIPT

Mail Stop Amendment  
Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450

Enclosed are 2 sheets of formal drawings for the above-identified application.

It is believed that no fee or petition is associated with this communication. If, however, any fee or petition is due, Applicant hereby petitions the Commissioner for the same, and authorizes the Commissioner to charge payment of any fees associated with this communication to Deposit Account No. 10-0258.

Please also note that the following corrections need to be made to the filing information as it appeared on the filing receipt:

- The docket number should read 007034 USAP02/DSM/BCVD/JW.
- The amount of drawings registered should be 2.
- The correct spelling of inventor no. 3 is Josephine J. Chang.

Respectfully submitted,  
JANAH & ASSOCIATES, P.C.

Dated: August 30, 2004

By: 

Ashok K. Janah  
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Please continue to direct all correspondence to: Applied Materials, Inc.  
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P.O. Box 450A  
Santa Clara, CA 95052

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450.

By: 

Hilde Susan Jaegtnes

Date August 30, 2004